

# Low temperature sintering of $(\text{Zn}_{1-x}, \text{Mg}_x)\text{TiO}_3$ microwave dielectrics

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## Abstract

The effects of glass additives and milling process on the microwave dielectric properties of  $(\text{Zn}_{1-x}, \text{Mg}_x)\text{TiO}_3$  (ZMT) ceramics were investigated. Three glasses including  $\text{B}_2\text{O}_3\text{--SiO}_2\text{--ZnO--Na}_2\text{O}$  (B–Si–Zn–Na),  $\text{B}_2\text{O}_3\text{--SiO}_2\text{--ZnO--K}_2\text{O}$  (B–Si–Zn–K) and  $\text{B}_2\text{O}_3\text{--K}_2\text{O--MnCO}_3$  (B–K–Mn) were selected for this study. Host material  $(\text{Zn}_{0.6}\text{Mg}_{0.4})\text{TiO}_3$  was selected to be sintered with glasses in the temperature range of 900–1200 °C. For  $(\text{Zn}_{0.6}\text{Mg}_{0.4})\text{TiO}_3$  with 5 wt.% glass B–Si–Zn–K sintered at 1100 °C, the  $\epsilon_r$  and  $Q \times f$  values were 18 and 29,375, respectively. Taking advantage of satellite milling, the ZMT ceramics can be sintered at 950 °C with the density of 4.21 g/cm<sup>3</sup>,  $\epsilon_r = 19$ , and  $Q \times f = 18,957$ .

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## 1. Introduction

Due to the rapid development of wireless communication services, the microwave ceramic devices with high performance are desired. The materials used in UHF microwave ceramic devices need to satisfy three requirements, namely the high dielectric constant,  $\epsilon_r$ , high quality factor,  $Q$ , low and as close as possible to zero temperature coefficient of resonant frequency,  $\tau_f$ . In order to miniaturize the microwave devices, the size of dielectric components must also be reduced. Multilayer devices have been developed to increase the volume efficiency. In multilayer structure, it is necessary to lower the sintering temperature of the dielectrics in order to co-fire with low melting point and highly conductive internal electrode metals, such as silver, copper, and their alloys [1–3].

Introducing low melting glass additives, chemical processing, and fining particle size of the starting materials are three of the methods used to reduce the sintering temperature of the dielectrics. Among these methods, glass additives used in liquid phase sintering is the most effective

and least expensive [4]. Zinc titanate ( $\text{ZnTiO}_3$ ) is a promising candidate for low temperature sintering dielectrics, because it can be sintered at 1100 °C without sintering aids and can be sintered at temperature <900 °C with  $\text{B}_2\text{O}_3$  glass. But this phase will decompose as the sintering temperature is above 900 °C. Kim et al. studied in advance the phase stability by adding magnesium, and their microwave properties [5–8]. In order to extend the processing window, this paper studied the effect of ternary B–Si–Zn glass system on the sinterability and also discussed the effect of Mg content on the  $\text{ZnTiO}_3$  phase stability, processing conditions, and microwave properties.

## 2. Experimental procedure

$(\text{Zn}_{1-x}, \text{Mg}_x)\text{TiO}_3$  ( $x = 0\text{--}0.5$ ) powder as the host material was prepared by solid-reaction method. High purity oxides,  $\text{TiO}_2$  (99.9% Showa Denko G1),  $\text{ZnO}$  (99.9% Umicore) and  $\text{MgO}$  (99% PCF) were mixed and then calcined at 700 °C for 2 h, followed by pulverization, pressing and then sintering in the temperature range of 950–1300 °C with intervals of 50 °C for 4 h. Three glasses were used in this study. The composition for glasses A–C are listed in Table 1. These

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Table 1  
Chemical composition (wt.%) of glass

Glass	SiO <sub>2</sub>	B <sub>2</sub> O <sub>3</sub>	Al <sub>2</sub> O <sub>3</sub>	ZnO	Metal oxide
A	10.4	45.3	2.5	35.2	Na <sub>2</sub> O 6.6
B	9.5	44.0	4.5	33.5	K <sub>2</sub> O 8.5
C	–	41.67	–	–	K <sub>2</sub> O 41.67 MnCO <sub>3</sub> 6.67

glasses were made by melting mixture of oxides at 1000 °C for 30 min and quenching. The calcined host material with 5 wt.% glasses were mixed by wet ball mill with water as the milling medium for 8 h. The dry-pressed and glass-doped samples were sintered at intervals of 50 °C over the temperature range of 950–1200 °C for 4 h. XRD analysis was undertaken for phase identification using Rigaku D/MAX-B. The microstructure was observed by SEM (Hitachi S-4700) attached with EDS (Horiba 7200-H). The densification behavior was evaluated by determining the bulk density using Archimedes technique. Dielectric properties were measured by a cavity method using Agilent 8722ES network analyzer.

### 3. Results and discussion

The XRD result of 700 °C and 2 h calcined powders of  $(\text{Zn}_{1-x}, \text{Mg}_x)\text{TiO}_3$  with  $x = 0-0.5$  shows that the major phase was hexagonal  $(\text{Zn}, \text{Mg})\text{TiO}_3$  and the  $\text{TiO}_2$  and  $\text{Zn}_2\text{Ti}_3\text{O}_8$  were minority.  $\text{TiO}_2$  phase increased with the increasing Mg content. The existence of  $\text{TiO}_2$  phase in Mg-rich systems seems to arise from the insufficient reaction of MgO with other oxides.

The  $(\text{Zn}_{1-x}, \text{Mg}_x)\text{TiO}_3$  with  $x = 0$  decomposed as the sintering temperature was greater than 950 °C as shown in Fig. 1(a–c). Fig. 2 shows the SEM photo of sample sintered at 1100 °C, where the dark rutile grain can be observed. The MgO additives could uplift the temperature of decomposition. The X-ray diffraction patterns of sample with  $x = 0.4$  are showed in Fig. 1(d–f). The pure  $(\text{Zn}, \text{Mg})\text{TiO}_3$  can be kept until 1200 °C. The SEM photo of 1100 °C sintered

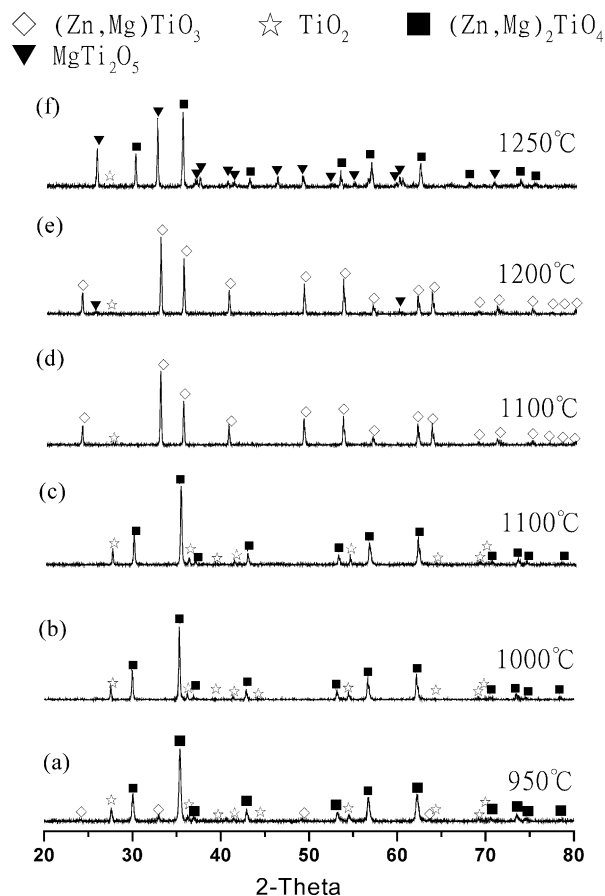


Fig. 1. XRD patterns of specimens with  $x = 0$  (a–c) and  $x = 0.4$  (d–f).

sample with  $x = 0.4$  in Fig. 2b shows the single phase of ZMT. Table 2 shows that the phase components of the ZMT with the different Mg content changing with the increasing temperature. The density of the sintered  $(\text{Zn}_{1-x}, \text{Mg}_x)\text{TiO}_3$  ceramics increased with sintering temperature and decreased with the increasing Mg content as shown in Fig. 3. As sample with  $x = 0.1$  sintered at 1000 °C and 1050 °C, the density decreased because of the hexagonal ZMT decomposing into cubic  $\text{Zn}_2\text{TiO}_4$  and rutile. The

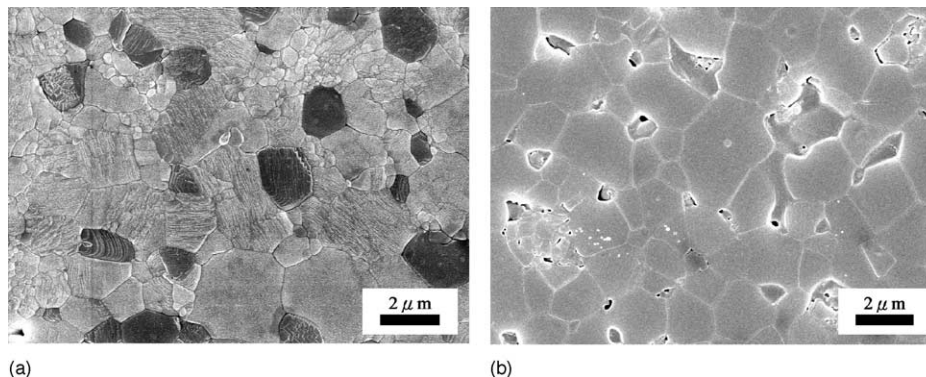


Fig. 2. SEM photos of  $(\text{Zn}_{1-x}, \text{Mg}_x)\text{TiO}_3$  specimens of  $x = 0$  (a) and  $x = 0.4$  (b), both were sintered at 1100 °C for 4 h.

Table 2

Phase components of the ZMT changing with Mg content and temperature

Sintered temperature (°C)	$x = 0$	$x = 0.1$	$x = 0.2$	$x = 0.3$	$x = 0.4$	$x = 0.5$
1300	■, ☆	■, ☆	▼, ■, ☆	▼, ■, ☆	▼, ■, ☆	▼, ■, ☆
1250	■, ☆	■, ☆	▼, ■, ☆	▼, ■, ☆	▼, ■, ☆	◇, ▼, ■
1200	■, ☆	■, ☆	■, ☆, ◇	◇, ☆	◇, ☆, ▼	◇, ▼
1150	■, ☆	■, ☆	■, ☆, ◇	◇, ☆	◇, ☆	◇, ▼
1100	■, ☆	■, ☆	◇	◇, ☆	◇, ☆	◇, ☆, ▼
1050	■, ☆	■, ☆, ◇	◇	◇, ☆	◇, ☆	◇, ☆
1000	■, ☆	◇	◇	◇, ☆	◇, ☆	◇, ☆
950	◇, ■, ☆	◇	◇	◇	◇	◇, ☆

(◇) (Zn, Mg)TiO<sub>3</sub>, (■) (Zn, Mg)<sub>2</sub>TiO<sub>4</sub>, (☆) TiO<sub>2</sub>, (▼) MgTi<sub>2</sub>O<sub>5</sub>.

similar phenomena can be observed in the samples with  $x = 0.3$  and  $0.4$  at the temperature greater than  $1200^\circ\text{C}$ . The sample with  $x \geq 0.2$  sintered at  $1200^\circ\text{C}$  showed the decreasing of density because of the precipitation of MgTi<sub>2</sub>O<sub>5</sub>. The microwave dielectric properties are shown in Figs. 4 and 5. The  $\epsilon_r$  values increased with the increasing temperature due to the more densification with higher temperature. The  $\epsilon_r$  values decreased with the increasing of Mg content because of the MgTiO<sub>3</sub> component in the ZMT solid solution, which has a lower dielectric constant ( $\epsilon_r = 17$ ). The  $Q \times f$  values in Fig. 5 shows that, in general, the samples sintered below  $1050^\circ\text{C}$  have lower  $Q \times f$  values because of lower density, and the samples with lower Mg content and sintered at temperature higher than  $1100^\circ\text{C}$  have the lower  $Q \times f$  values because of the decomposition of hexagonal ZMT phase into cubic (Zn, Mg)<sub>2</sub>TiO<sub>4</sub> phase and rutile. The higher  $Q \times f$  values for the samples with higher Mg content sintered at higher temperature can be interpreted as that the Mg content stabilize the hexagonal ZMT phase and the higher sintering temperature enhance the densification. The excess Mg content ( $x > 0.4$ ) caused to the lower bulk density and  $Q \times f$  values.

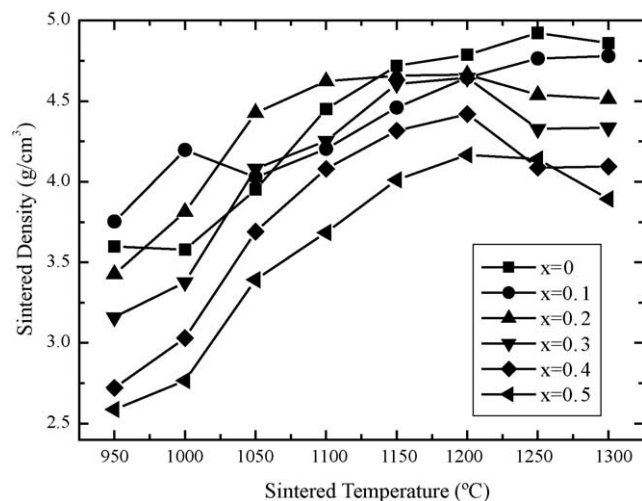
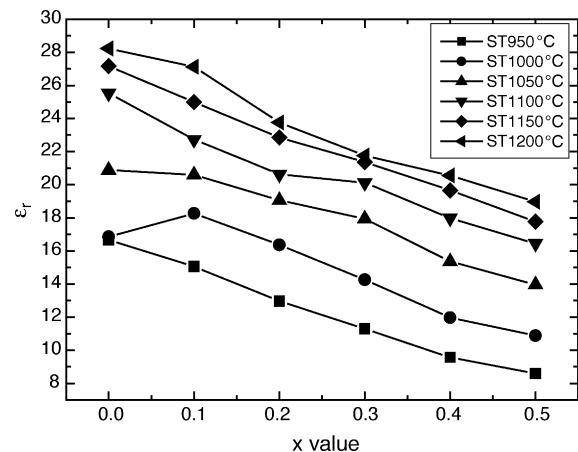
Fig. 3. Density curves for the (Zn<sub>1-x</sub>, Mg<sub>x</sub>)TiO<sub>3</sub> ( $x = 0-0.5$ ) powder sintered from 950 to  $1300^\circ\text{C}$ .

Table 3

Dielectric properties of low fired ZMT

	$\epsilon_r$	$Q \times f$
H.M. + 5 wt.% glass A	18.0	7721
H.M. + 5 wt.% glass B	18.0	29375
H.M. + 4 wt.% glass + 1 wt.% CuO	17.9	20424
H.M. + 5 wt.% glass C	15.7	1246

Considering the phase stability and the higher  $Q \times f$  value, the ZMT with  $x = 0.4$  was used as the host material. The density of ZMT with addition of 5 wt.% glass increased with sintering temperature range from  $900$  to  $1100^\circ\text{C}$ , as shown in Fig. 6. The SEM photos of samples sintered at  $950^\circ\text{C}$  are shown in Fig. 7. The density decreased as the sintering temperature greater than  $1200^\circ\text{C}$  because of the decomposition of (Zn, Mg)TiO<sub>3</sub> and the precipitation of Zn<sub>2</sub>TiO<sub>4</sub> and TiO<sub>2</sub>. Specimens with glasses A and B had higher density than that with glass C. Glass A with 1 wt.% CuO addition failed to improve the densification and lower the sintering temperature. Due to the highest density was obtained at  $1100^\circ\text{C}$ , the measurements of  $\epsilon_r$  and  $Q$  values

Fig. 4. Dielectric constant of (Zn<sub>1-x</sub>, Mg<sub>x</sub>)TiO<sub>3</sub> ( $x = 0-0.5$ ) sintered from 950 to  $1200^\circ\text{C}$ .

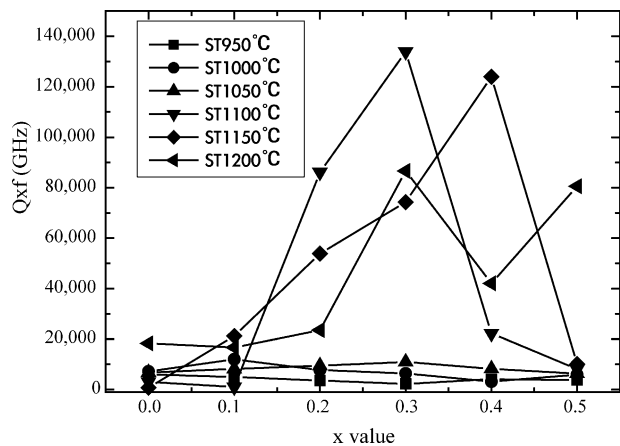


Fig. 5.  $Q \times f$  of  $(\text{Zn}_{1-x}, \text{Mg}_x)\text{TiO}_3$  ( $x=0-0.5$ ) sintered from 950 to 1200 °C.

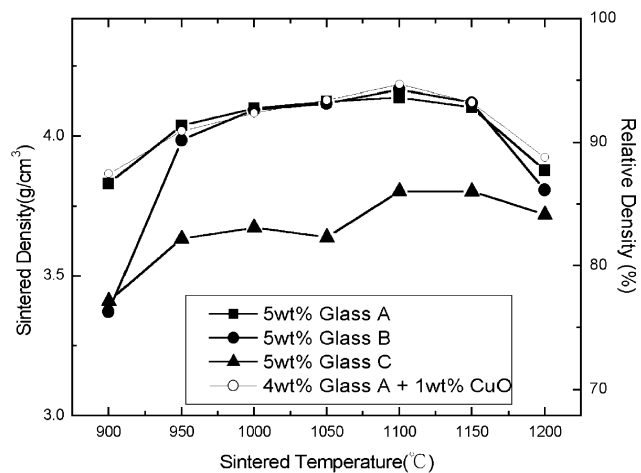


Fig. 6. Density curves of ZMT with addition of 5 wt.% glass sintered with intervals of 50 °C in the temperature range of 900–1200 °C.

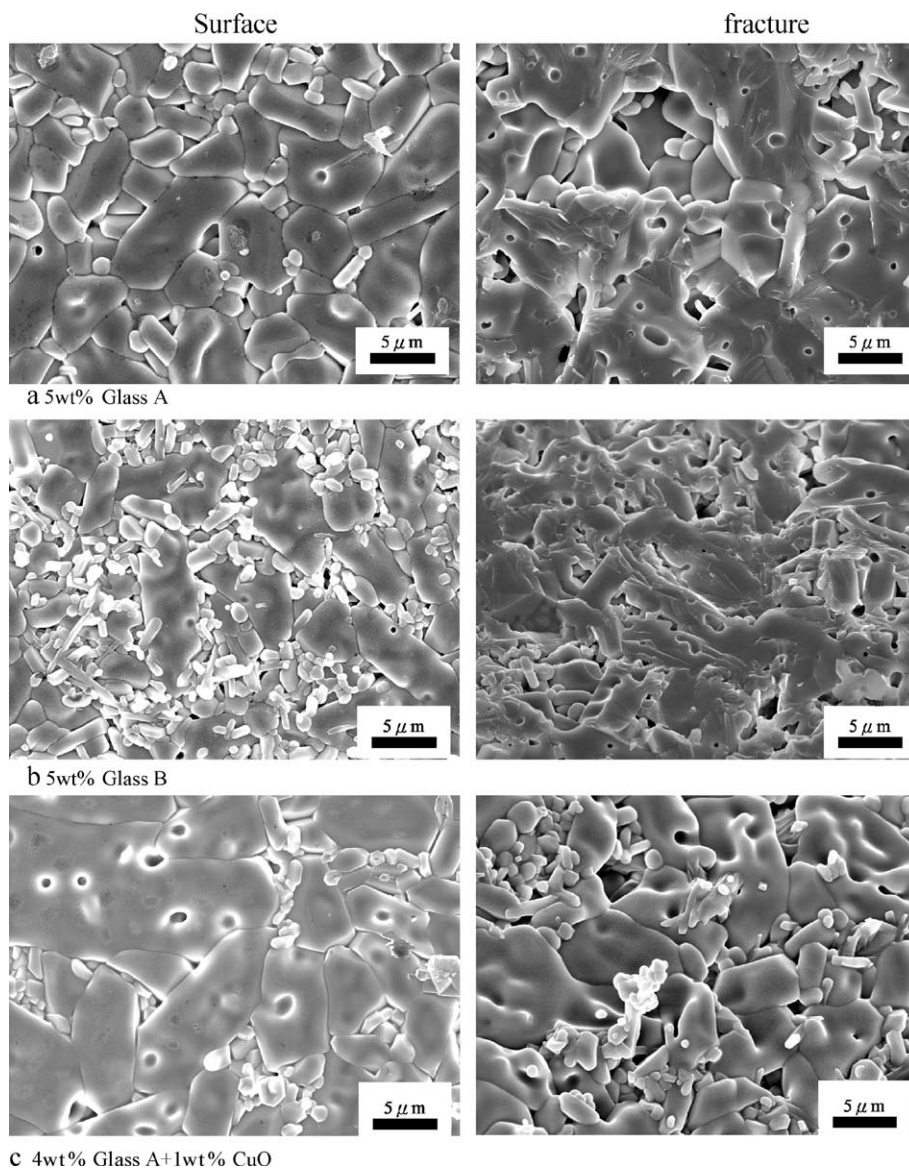


Fig. 7. SEM photos of surface and fracture microstructure of host material with glasses sintered at 950 °C.

Table 4

Microwave dielectric properties of samples milled for 8 h and sintered in temperature range of 900 to 1200 °C

	Sintered temperature (°C)						
	900	950	1000	1050	1100	1150	1200
$\epsilon_r$	17.8	19.0	19.8	19.7	18.9	18.6	17.3
$Q \times f$	18547	18957	20101	21179	17937	15253	18532

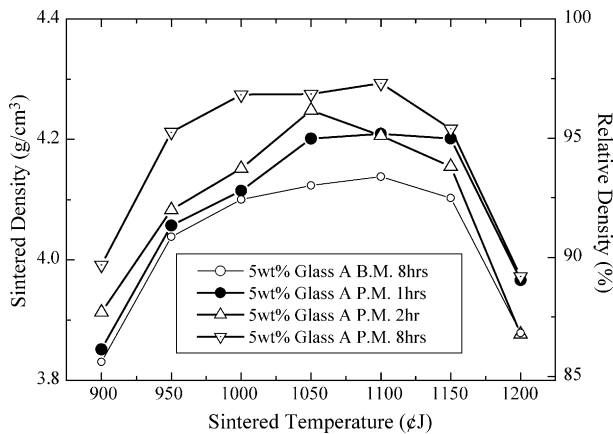


Fig. 8. Sintered density curves of samples milled by satellite mill.

were performed on these samples. Table 3 shows the properties of low fired ZMT. The  $\epsilon_r$  and  $Q \times f$  values for sample with glass B were reduced to 18 and 29,375, respectively.

The sample with glass A had higher density and, therefore, was chosen to be milled by satellite ball mill. After milling for 1, 2 and 8 h, the grain size ( $d_{50}$ ) were 1.37, 1.21 and 0.83  $\mu\text{m}$ , respectively. As shown in Fig. 8, compared to the sample milled by traditional ball mill, the densification of samples milled by satellite mill were significantly improved and the sintering temperature can be lowered to 950 °C. After 8 h milling, the density of 4.21 g/cm<sup>3</sup> (95% relative density) can be obtained at 950 °C. Table 4 shows the microwave dielectric properties of samples milled for 8 h and sintered at temperature range from 900 to 1200 °C.  $\epsilon_r = 19$  and  $Q \times f = 18,957$  can be obtained at sintering temperature 900 °C.

#### 4. Conclusion

Microwave material  $(\text{Zn}_{0.6}\text{Mg}_{0.4})\text{TiO}_3$  were sintered in the temperature range of 900–1200 °C with the addition of  $\text{B}_2\text{O}_3\text{--SiO}_2\text{--ZnO}$  glass system. For  $(\text{Zn}_{0.6}\text{Mg}_{0.4})\text{TiO}_3$  sintered with 5 wt.% glass B at 1100 °C, the  $\epsilon_r$  and  $Q \times f$  values were 18 and 29,375, respectively. Taking advantage of satellite milling, the ZMT ceramics can be sintered at 950 °C with the density of 4.21 g/cm<sup>3</sup>,  $\epsilon_r = 19$ , and  $Q \times f = 18,957$ .

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